

# High efficiency silicon heterojunction solar cells: From conventional concepts to a 3<sup>rd</sup> generation bi-triplet exciton generating hybrid device

**M. Liebhaber**

E-mail: [martin.liebhaber@helmholtz-berlin.de](mailto:martin.liebhaber@helmholtz-berlin.de)

Helmholtz Center Berlin  
Institute for Nanospectroscopy  
Energy Materials In-Situ Lab

# Where I come from...



## Berlin City



## Helmholtz Center Berlin



Energy Materials In-Situ Lab

## Valence band offset and hole transport in c-Si/a-SiO<sub>x</sub> heterojunction solar cells

### Cooperation:

Institut für Silicon Photovoltaics (HZB)



Lars Korte



Mathias Mews

...many more people involved

### Financial support:



Bundesministerium  
für Bildung  
und Forschung

### “SISSY” project

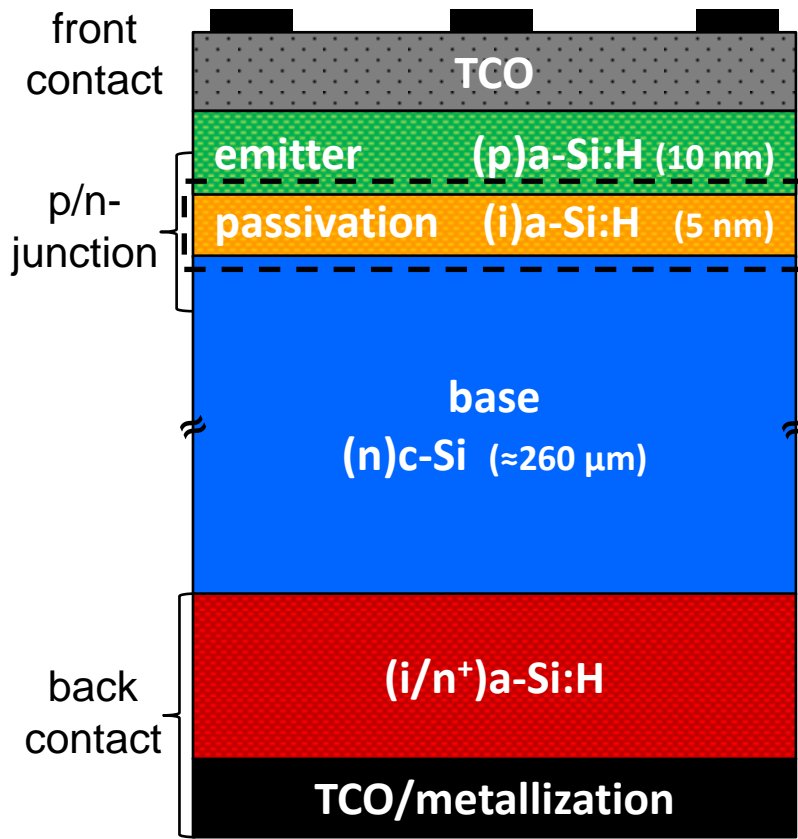
Grant No. 03SF0403



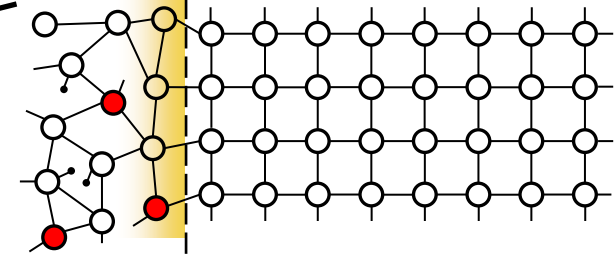
### HERCULES

Grant No. 608498

## SHJ solar cell (Silicon Heterojunction)

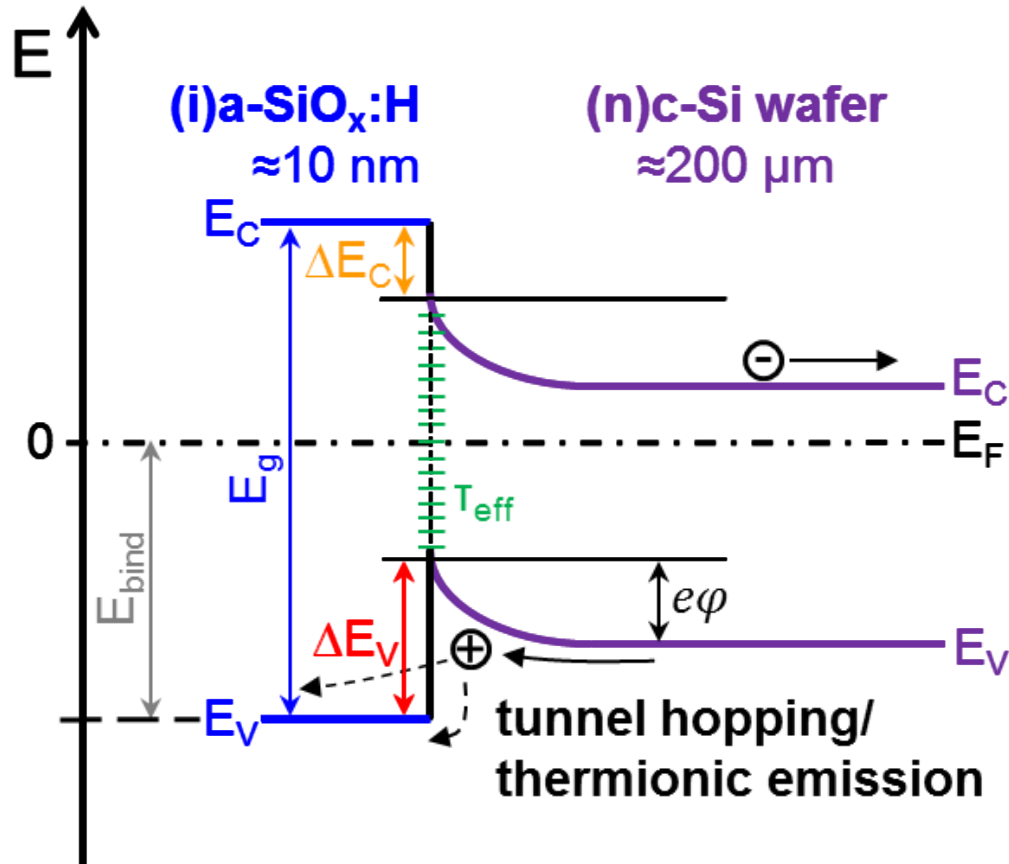


amorphous | crystalline heterojunction



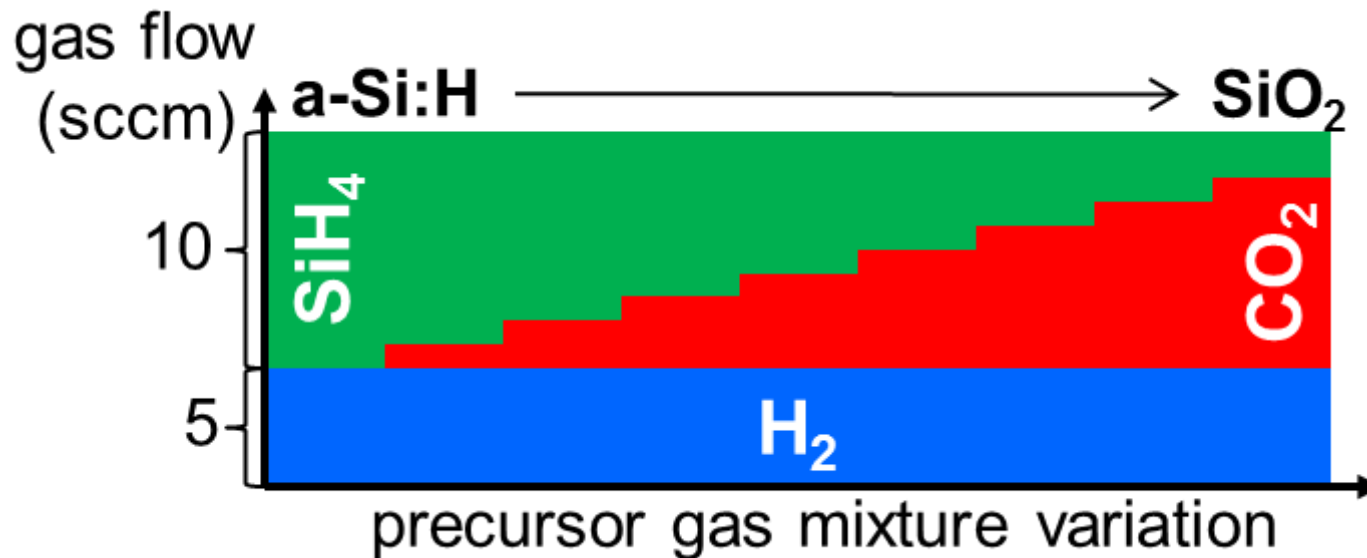
$(i)a-SiO_x:H$

- ▶ excellently passivated contacts
- ▶ **world record** for Si based PV:  
 $\eta = 25.6\% / 22.5\%$  (Panasonic, 2014/2015)
- ▶ reduce parasitic absorption
  - wide band gap materials
  - band offset modification



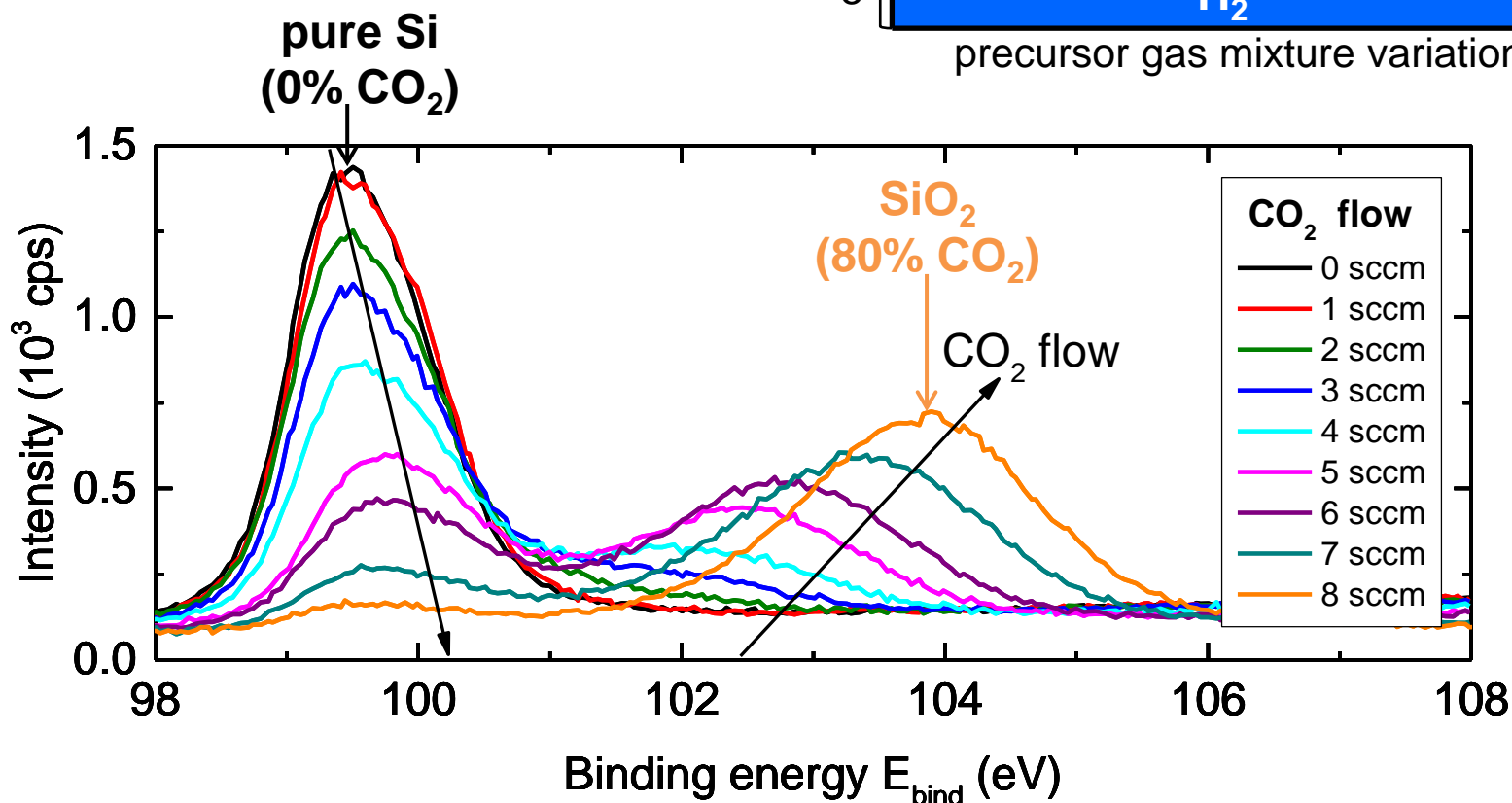
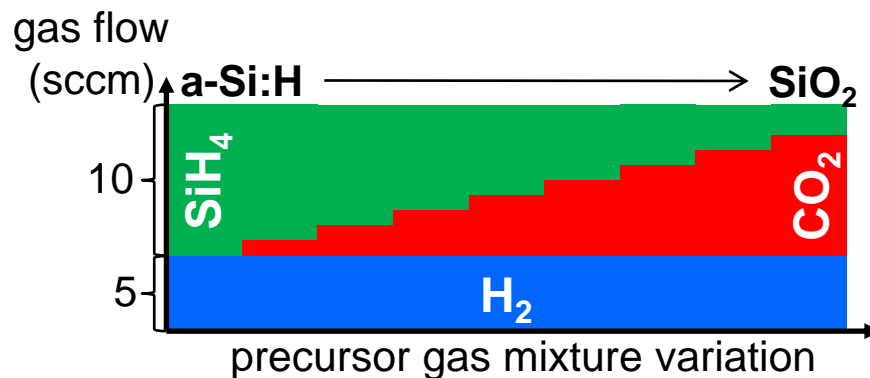
- ▶ **heterojunction parameter**
  - optical band gap  $E_g$
  - band offsets  $\Delta E_v$ ,  $\Delta E_c$
  - surface passivation  $T_{eff}$
- ▶ **FOCUS** on  $\Delta E_v$  of
  - **a-SiO<sub>x</sub>:H/c-Si** heterointerface
  - **hole transport mechanism**

- ▶ **PECVD** layer deposition (Plasma Enhanced Chemical Vapour Deposition)
  - varying precursor gas mixtures
  - change of *stoichiometry*  $x$  in  $a\text{-SiO}_x$  layers



► X-ray Photoelectron Spectroscopy

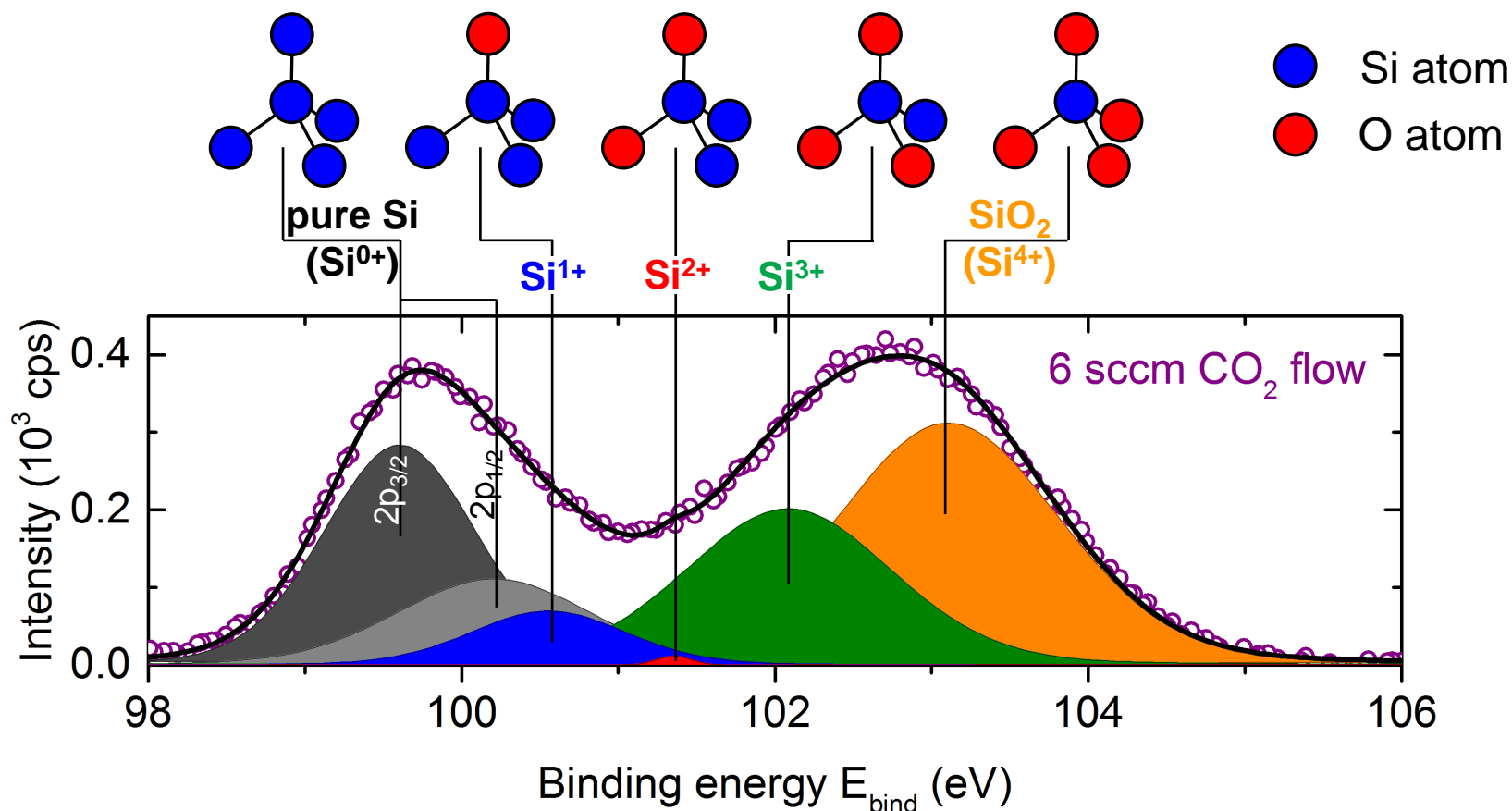
► Si 2p peak



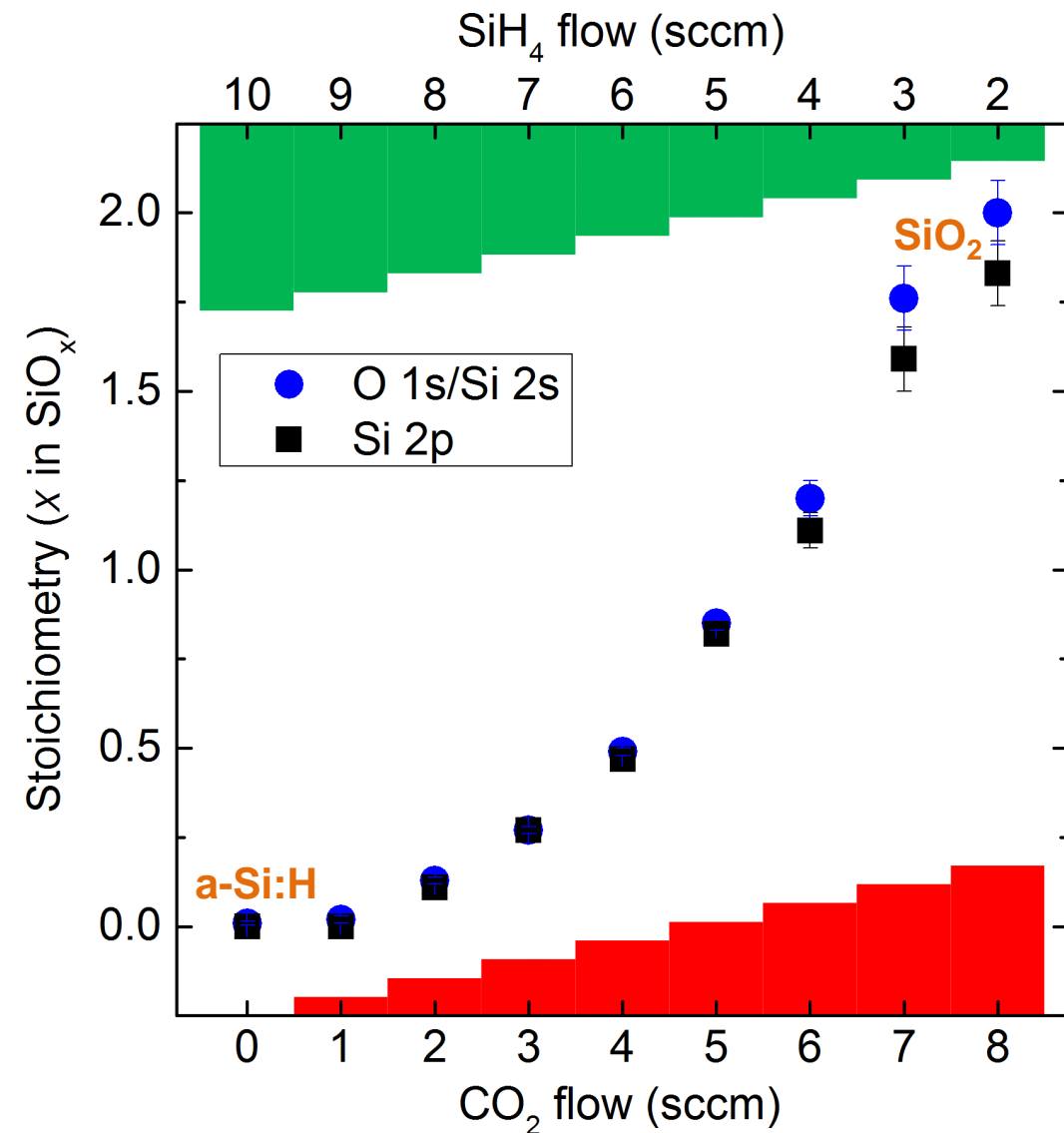
M. Liebhaber *et al.*, APL **106**, 031601 (2015)



- ▶ chem. shift of core level peak depends on oxidation states
- ▶ peak intensity ratios  $\leftrightarrow$  oxygen concentration

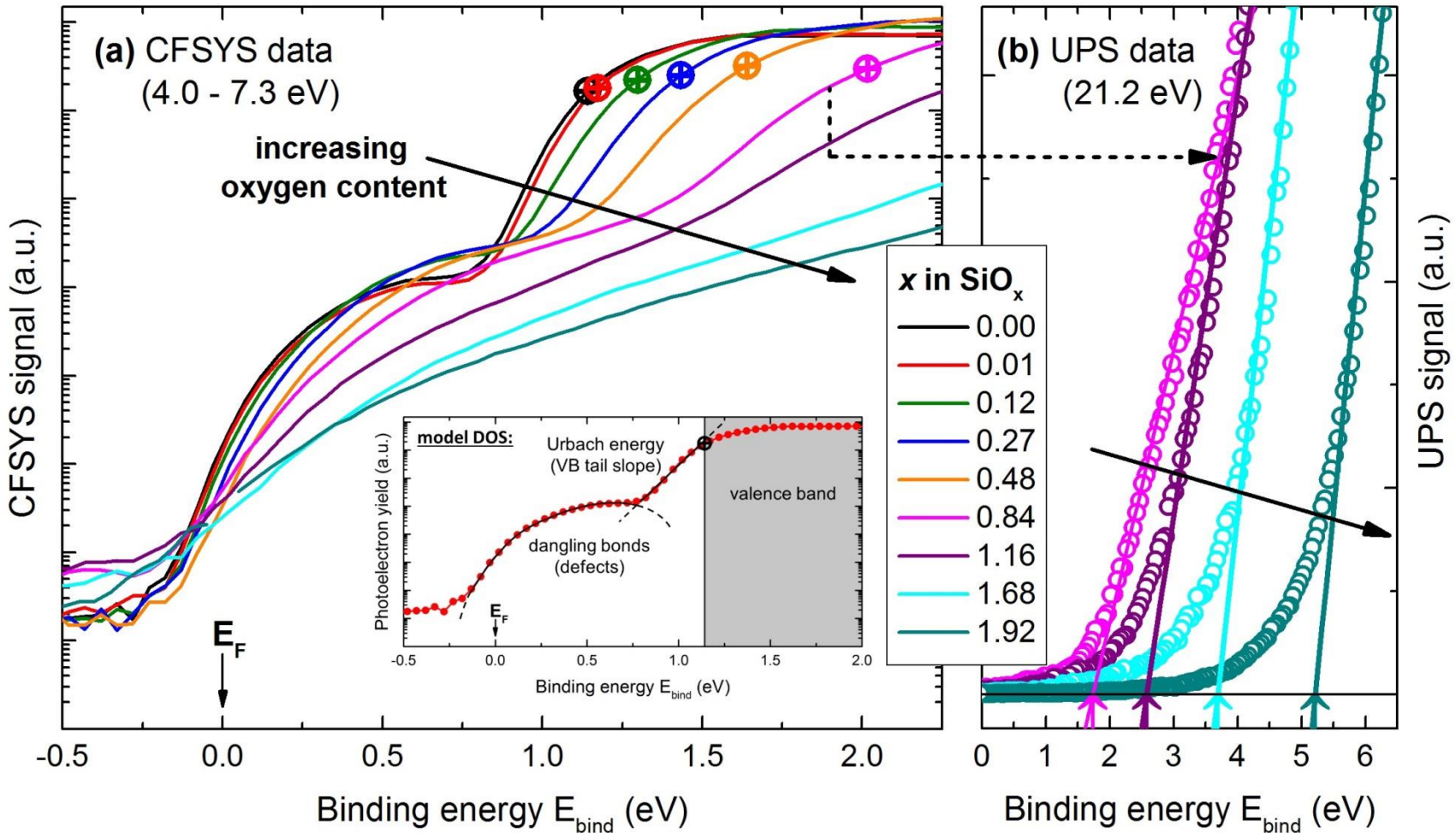


M. Liebhaber *et al.*, APL **106**, 031601 (2015)



- ▶ cross-check with other peaks
- ▶ **conversion:**  
SiH<sub>4</sub>/CO<sub>2</sub> ratio → oxygen conc.
- ▶ non linear dependency of stoichiometry on gas phase composition

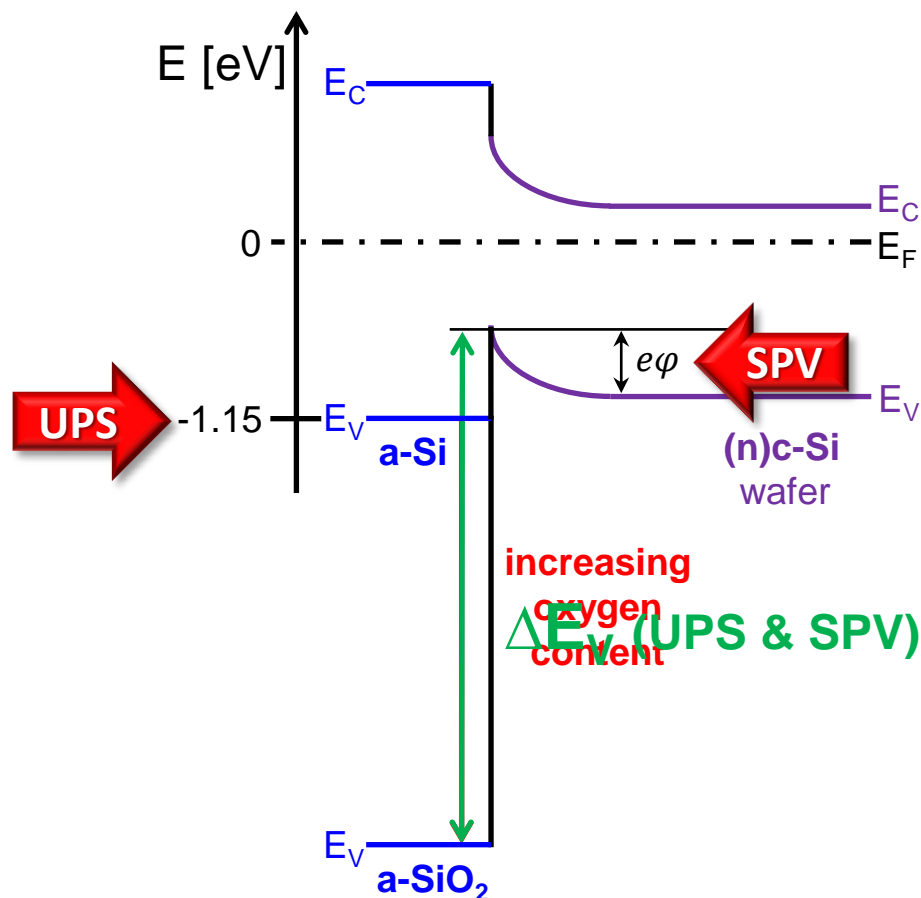
- ▶ **U**ltraviolet **P**hotoelectron **S**pectroscopy
- ▶ obtain valence band position relative to  $E_F$

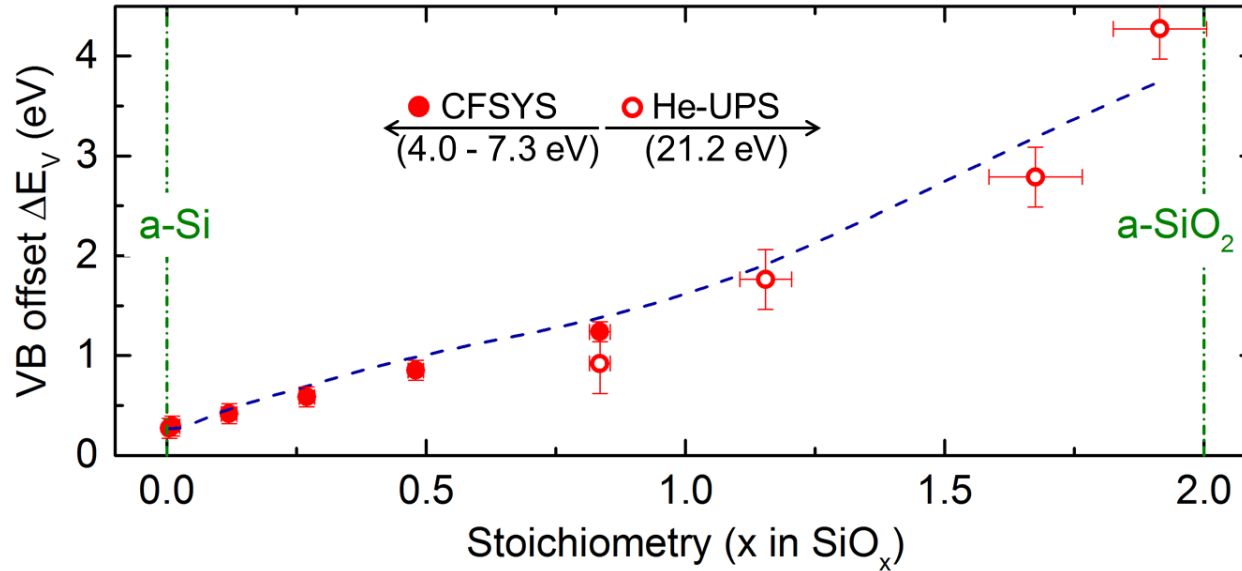


[1] L. Korte *et al.*, JAP **109**, 063714 (2011)  
M. Liebhaber *et al.*, APL **106**, 031601 (2015)

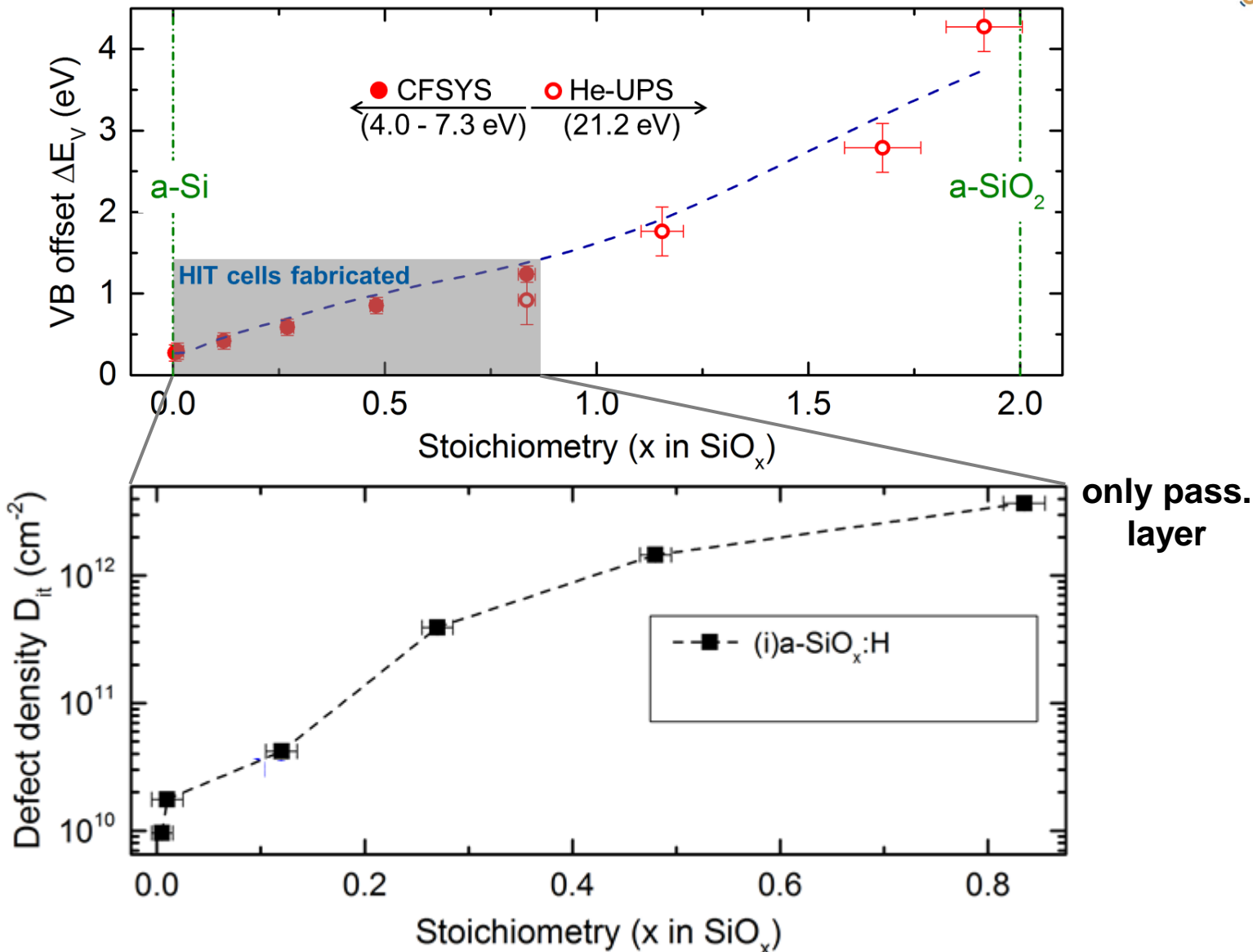
- **UPS:** valence band position (relative to  $E_F$ )
- **SPV:** band bending  $\leq 150$  meV

**U**ltraviolet **P**hotoelectron **S**pectroscopy  
**S**urface **P**hoto**V**oltage



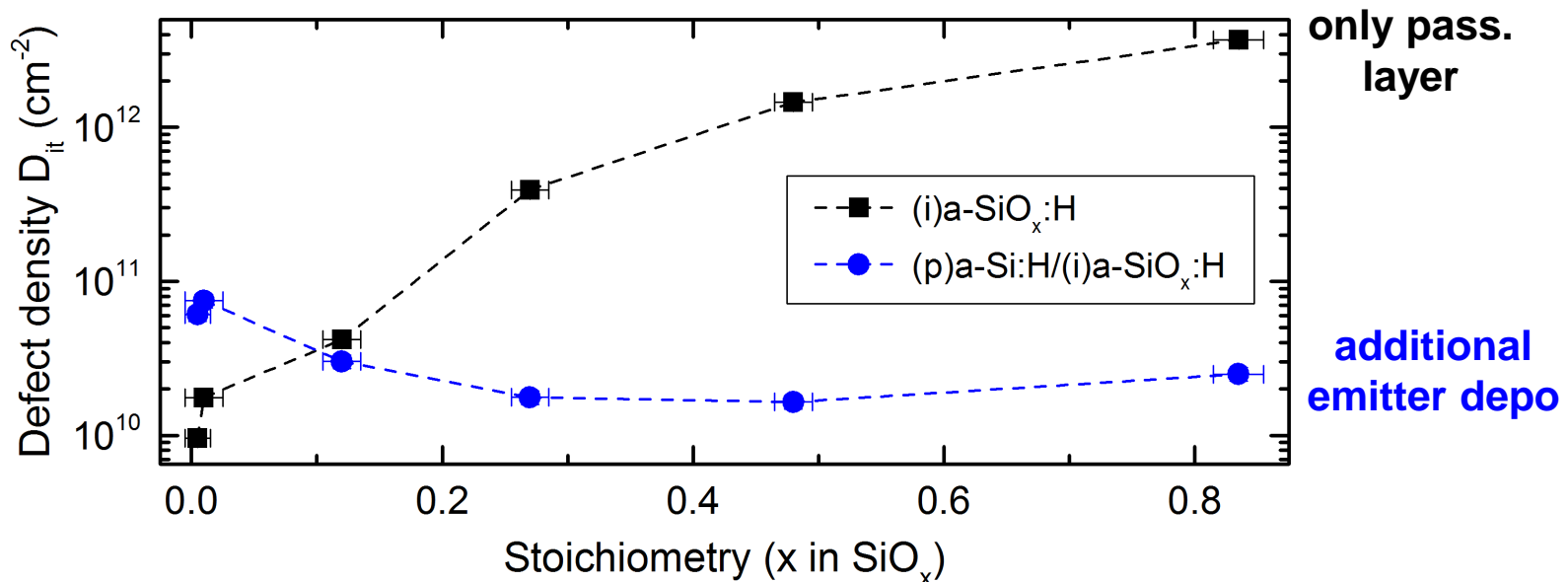


- ▶ dependency of  $\Delta E_V$  on stoichiometry
- ▶ direct correlation of  $\Delta E_V$  on cell performance

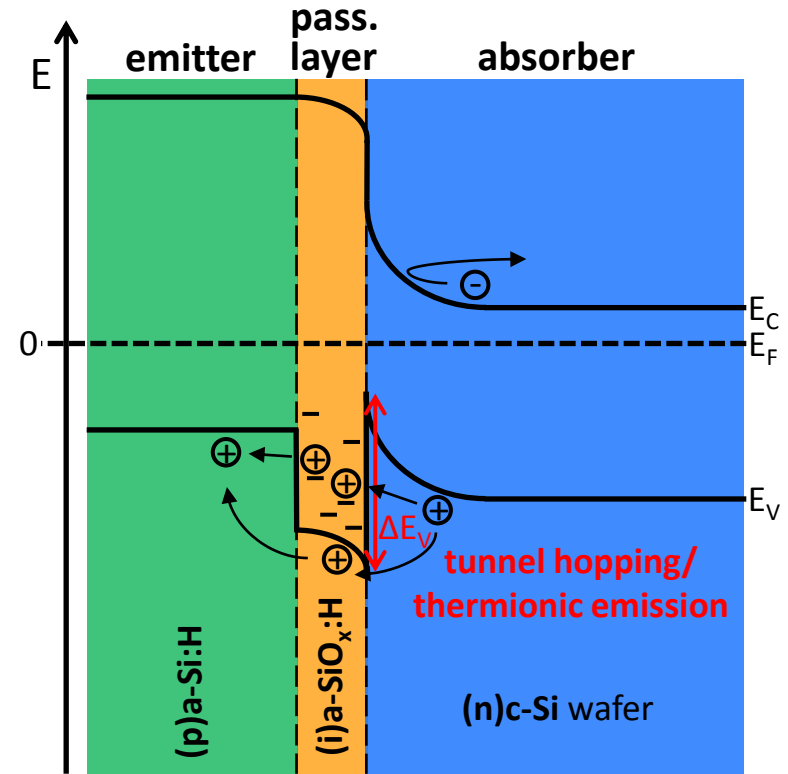
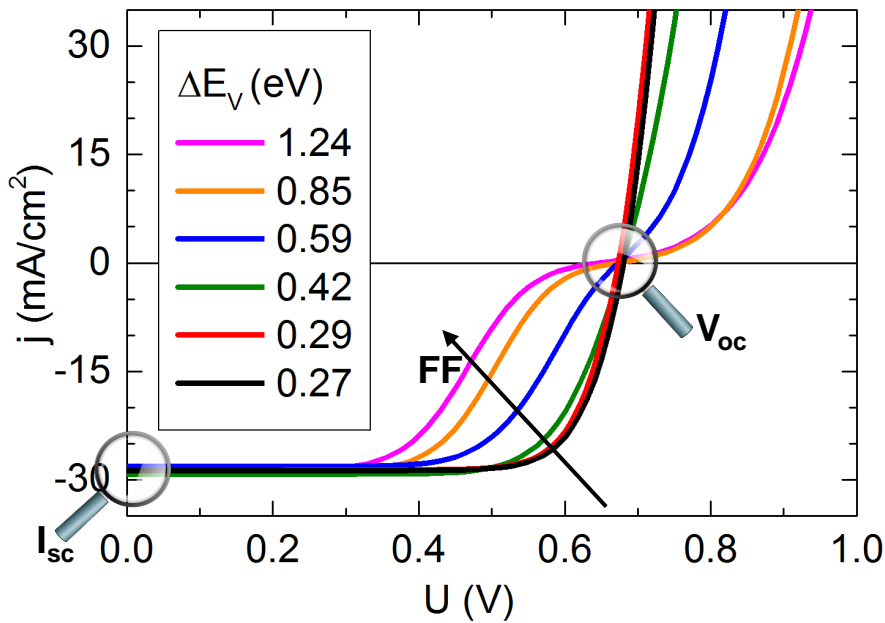


M. Liebhaber *et al.*, APL **106**, 031601 (2015); M. Mews, M. Liebhaber *et al.*, APL **107**, 013902 (2015)

- ▶ increasing  $D_{it}$  for rising oxygen concentration
  - but decrease drastically after emitter deposition
  - similar passivation quality as standard interface
- ▶ dangling bonds at the SHJ are saturated by hydrogen during additional plasma process (emitter deposition)



M. Liebhaber *et al.*, APL **106**, 031601 (2015); M. Mews, M. Liebhaber *et al.*, APL **107**, 013902 (2015)



## ► solar cell parameter

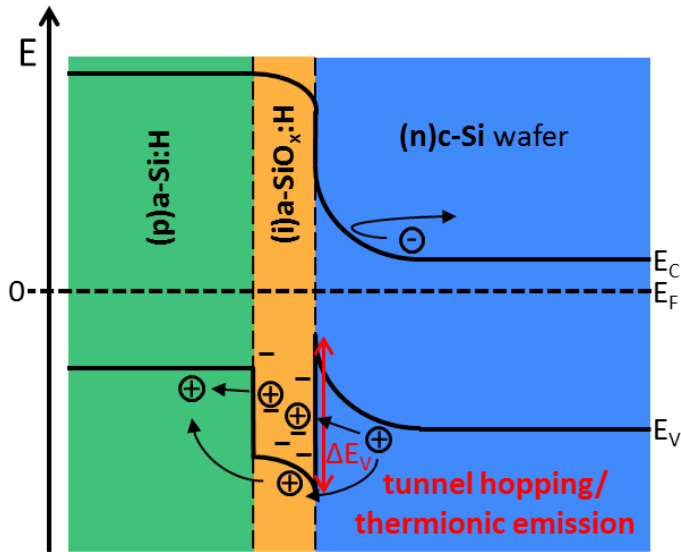
- surface passivation ( $\rightarrow V_{oc}$ )
  - OK
- widening of band gap ( $\rightarrow I_{sc}$ )
  - thin layer (small effect expected)
- band offsets ( $\rightarrow FF$ )
  - transport barrier

## ► hole transport mechanism

- transport barrier reflected in **FF**
  - **thermionic emission** (for small  $\Delta E_V$ )
  - **tunnel hopping** through tail states (additional for higher  $\Delta E_V$  [1])

[1] A. Kanevce *et al.*, JAP **105**, 094507 (2009)  
M. Mews, M. Liebhaber *et al.*, APL **107**, 013902 (2015)



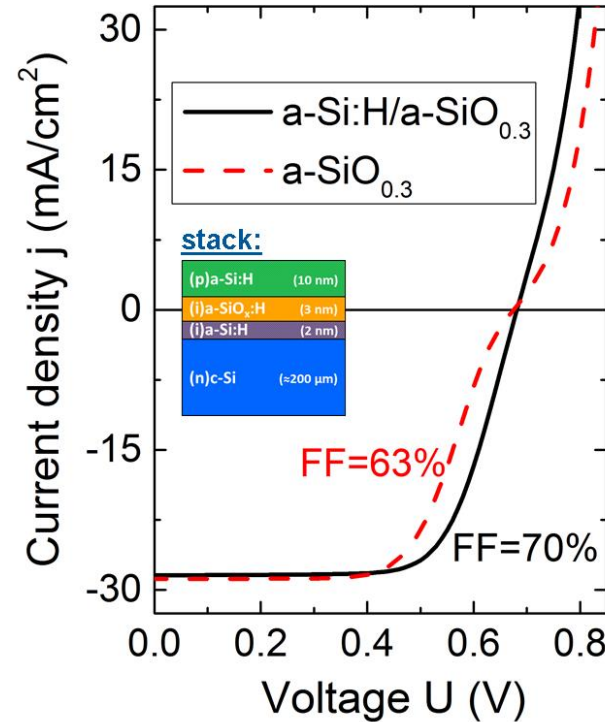


single layer  
split into  
layer stack



$$\Delta E_{V,a-Si:H} = 270 \text{ meV}$$

$$\Delta E_{V,a-SiO_{0.3}:H} = 585 \text{ meV}$$



- ▶ **“staircase” of valence band offsets**
  - improved FF for HIT cell with **stacked passivation layers**
- ▶ **promising concept:** combination of
  - moderate band gap passivation layer
  - high band gap hole contact layer

M. Mews, M. Liebhaber *et al.*, APL **107**, 013902 (2015)

- ▶ growth of **(i)a-SiO<sub>x</sub>:H** thin films (PECVD)
  - **stoichiometry** (XPS)
  - $\Delta E_v$  (UPS/SPV)
  - sufficient **passivation**
- ▶ implemented into **SHJ cells** (low x-regime)
  - **FF** directly **linked to**  $\Delta E_v$
  - discussion of **hole transport mechanism**  
(thermionic emission vs. tunnel hopping)

**general challenge:** transport limitation due to band offset induced by the high band gap of a-SiO<sub>x</sub>

**possible solution:** band gap “staircase”  
also in combination with high band gap emitter

## Tetracene/c-Si hybrid solar cell – multi-exciton generation via singlet fission –



June/July '15

**DAAD**  
Deutscher Akademischer Austausch Dienst  
German Academic Exchange Service  
Project-ID 57140921



**Cooperation**

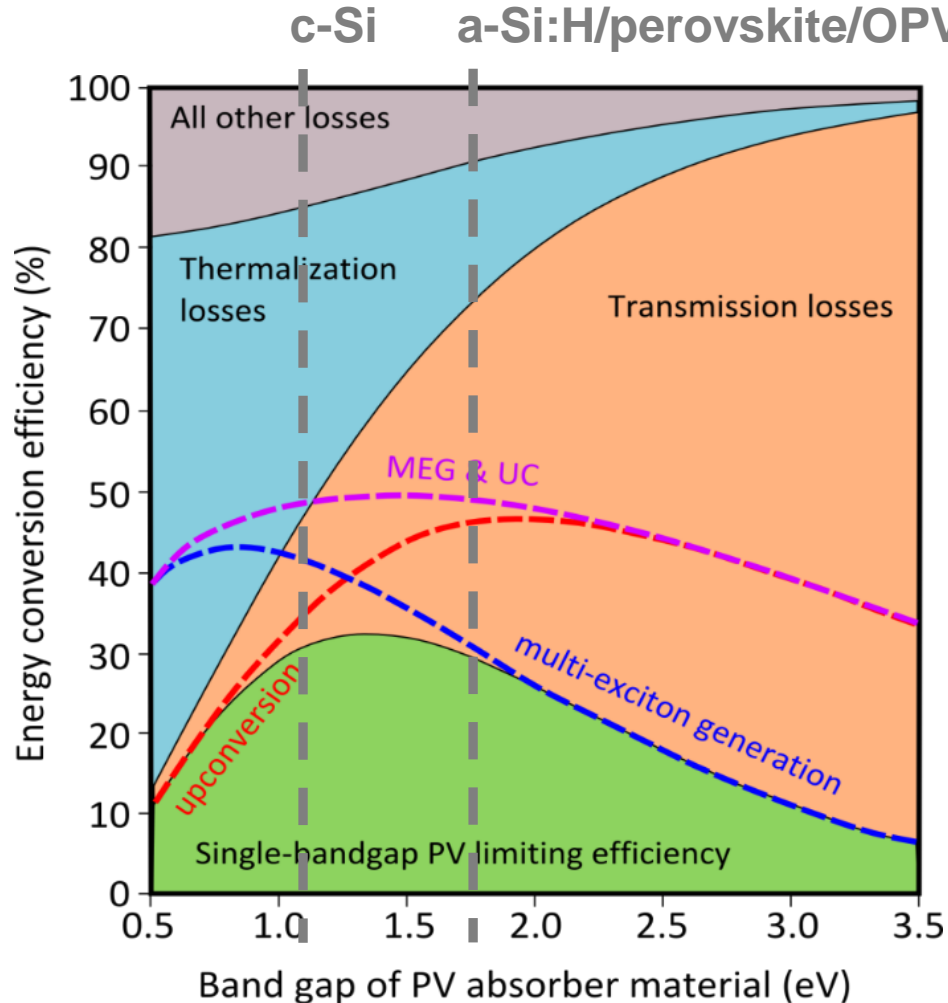


March '15



November '15

...many more people involved

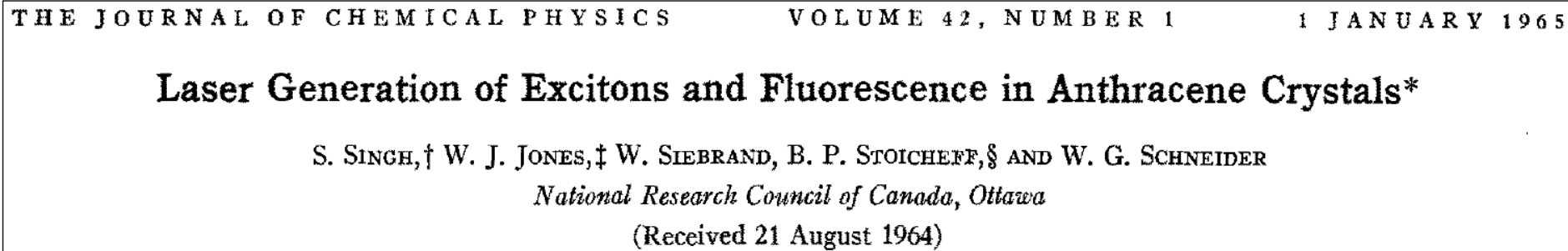


**UC:** TTA, Er-Yb,...

**MEG:** Si nanocrystals, SF...

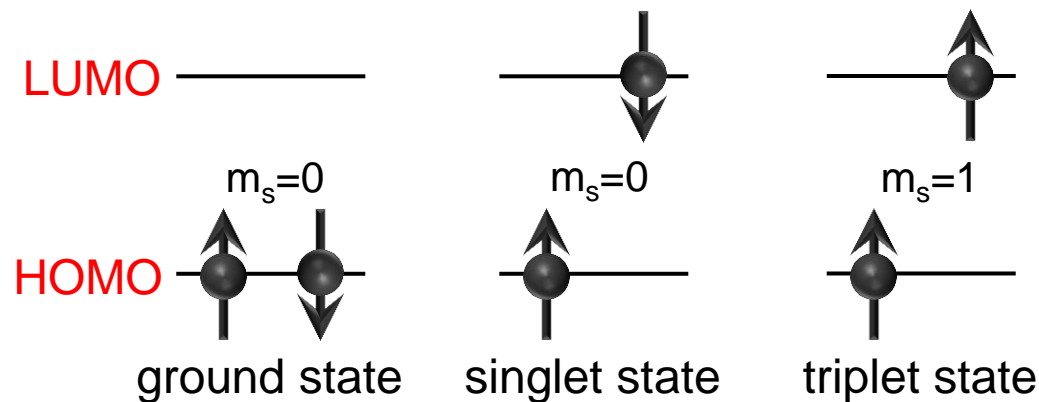
adapted from: L. C. Hirst and N. J. Ekins-Daukes, PIP **19**, 286 (2011)

- ▶ first observed in anthracene in 1965 by S. Singh *et al.*



- ▶ organic chromophore in **excited singlet state**
- ▶ **shares** its **excitation energy** with a **neighboring ground-state** chromophore
- ▶ both are converted into **correlated triplet excited states**

## molecular states of interest:



# MEG via Singlet Fission (SF): 1 photon $\rightarrow$ 2 $e^-h^+$ pairs

electronic transitions:

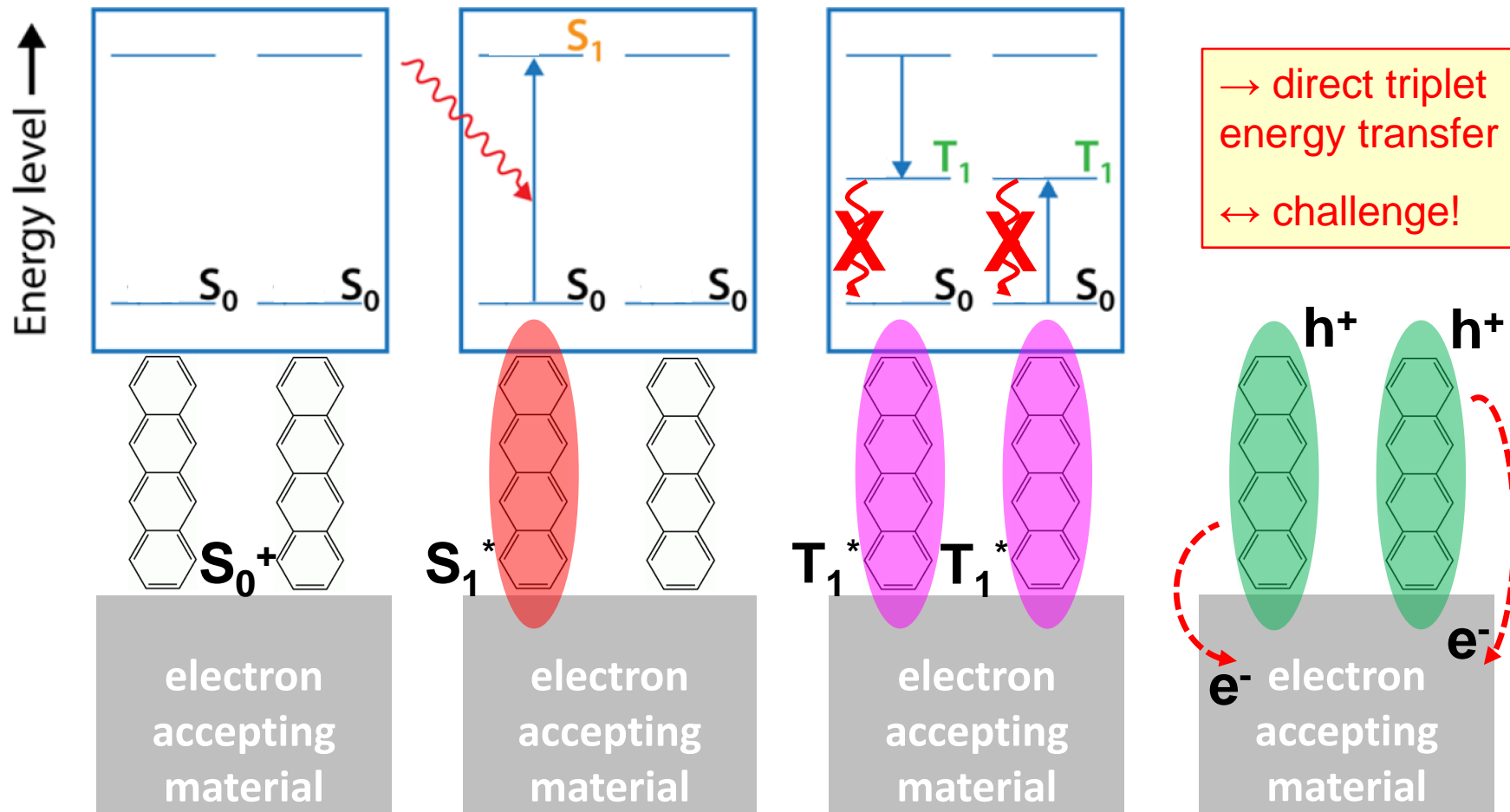
time  $\rightarrow$

**excitation**  
 $\approx 100$  fs

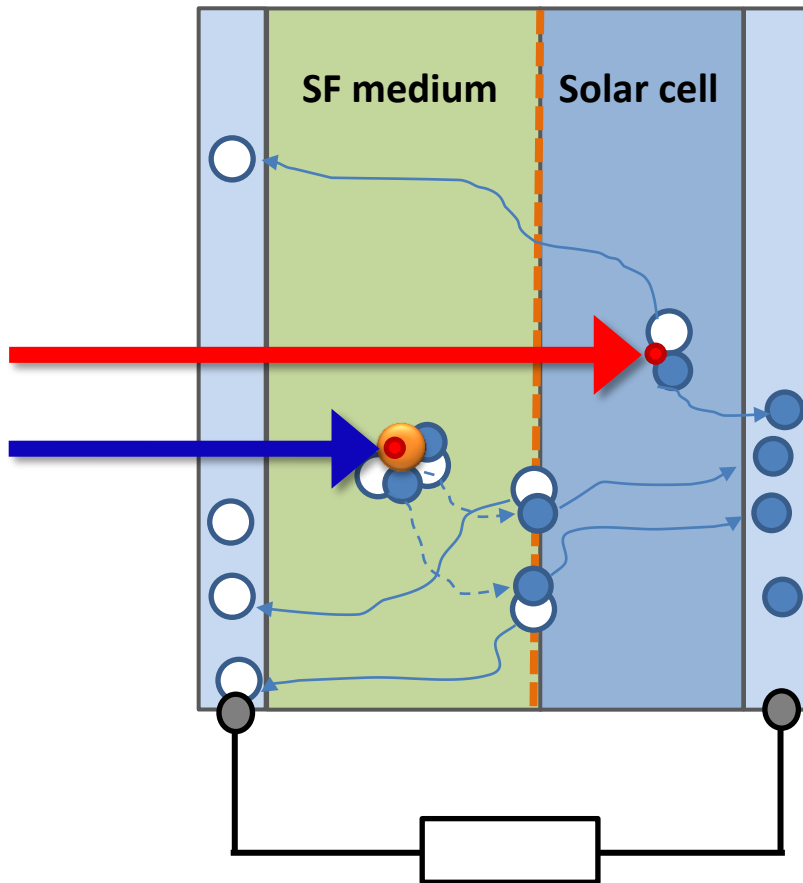
**fission**  
 $\approx 100$  ps

**triplet state**  
 $\approx 100$  ns

**ionization**  
ps – ms ??



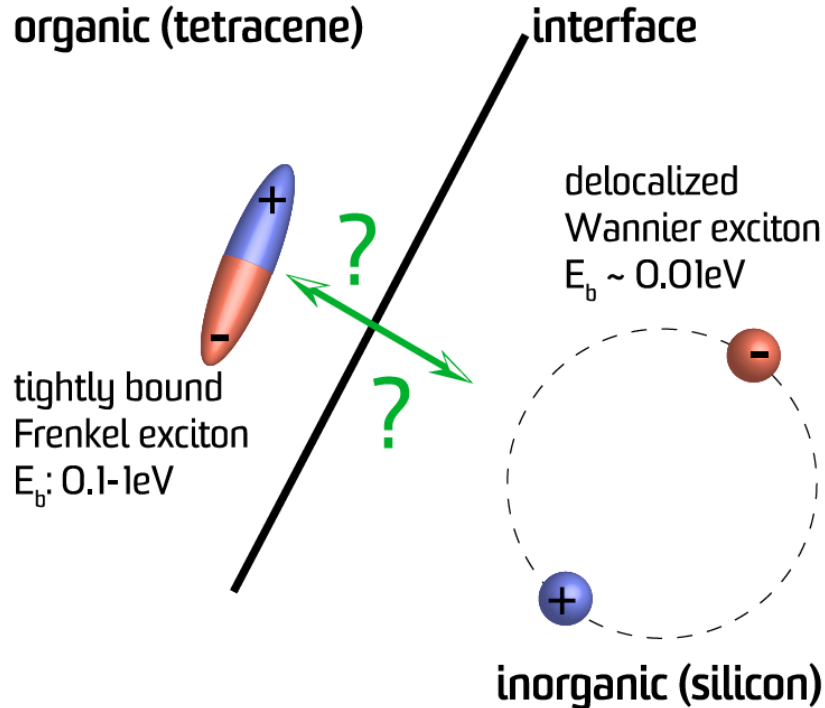
J. J. Burdett *et al.*, J. Chem. Phys. **133**, 144506 (2010)



## Prerequisite:

- ▶ triplet exciton diffusion length longer than thickness SF medium
- ▶ geminate triplet exciton pair dissociation at hybrid interface

absorption ●      Exciton/ electron-hole-pair ○      MEG event ●      Exciton migration carrier migration ↻



## 1. Charge transfer state

direct electron transfer with the hole on the organic & the electron on the inorganic material

## 2. Förster type transition

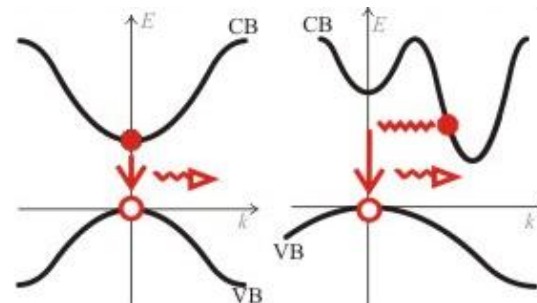
- non-radiative transfer mechanism (long range)
- dipole transition  $\leftrightarrow$  spin forbidden for triplets

## 3. Dexter type transfer

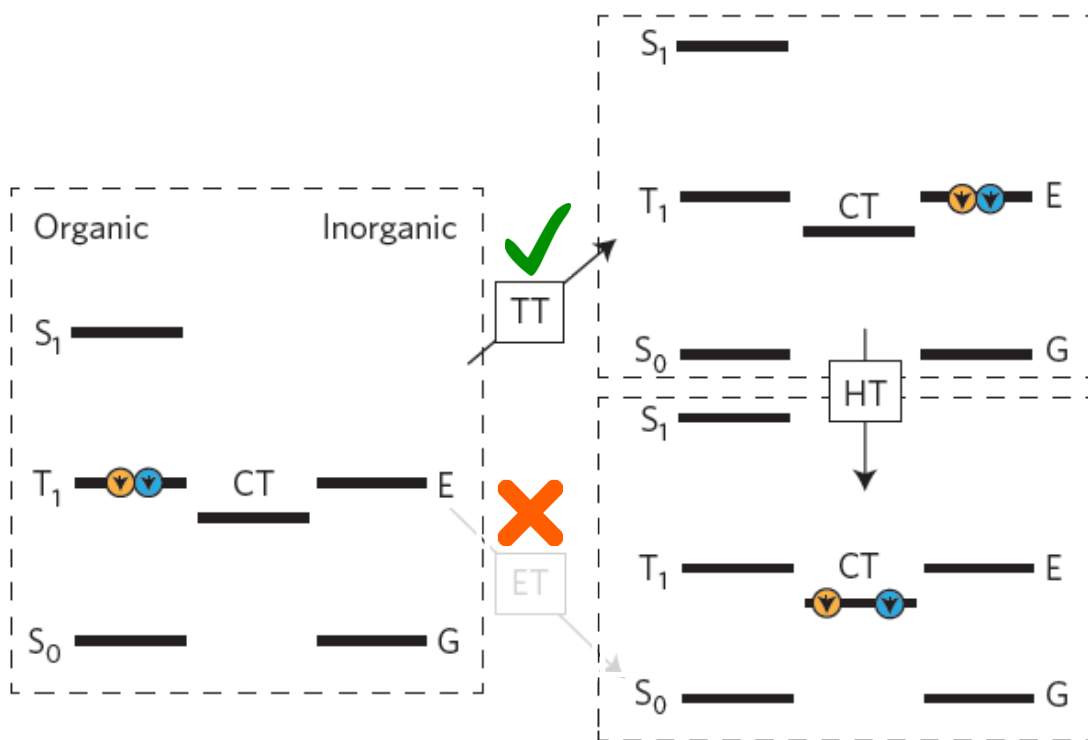
- charges/triplets move
- wave function overlap (short range)

## Challenges

- momentum conservation & localization effect  
→ direct vs. indirect semiconductors
- loose spin correlation  
→ easier in heavy atoms (spin-orbit coupling)







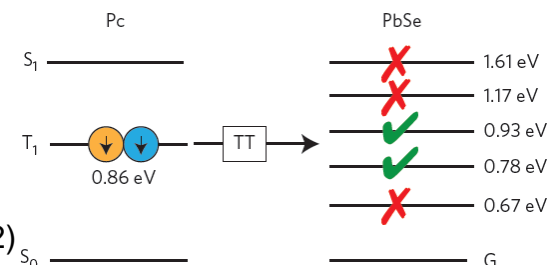
triplet transfer (TT) “dexter type” followed by hole transfer (HT) back

direct electron transfer (ET) via charge transfer state (CT)

▶ transient optical absorption measurements ↔ dynamics<sup>1)</sup>

▶ efficient transfer only at resonance ↔ size of NCs<sup>1)</sup>

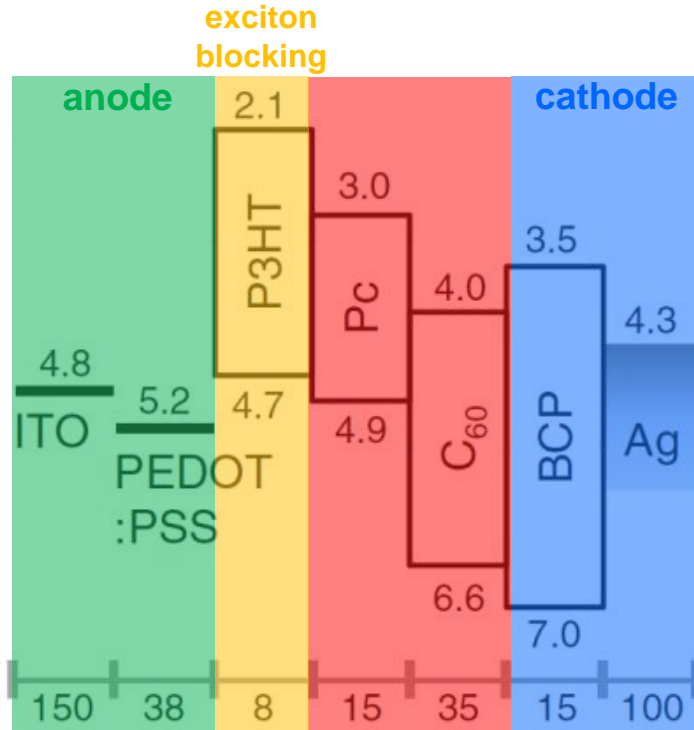
▶ exponential dependency of transfer efficiency ↔ NC ligands<sup>2)</sup>



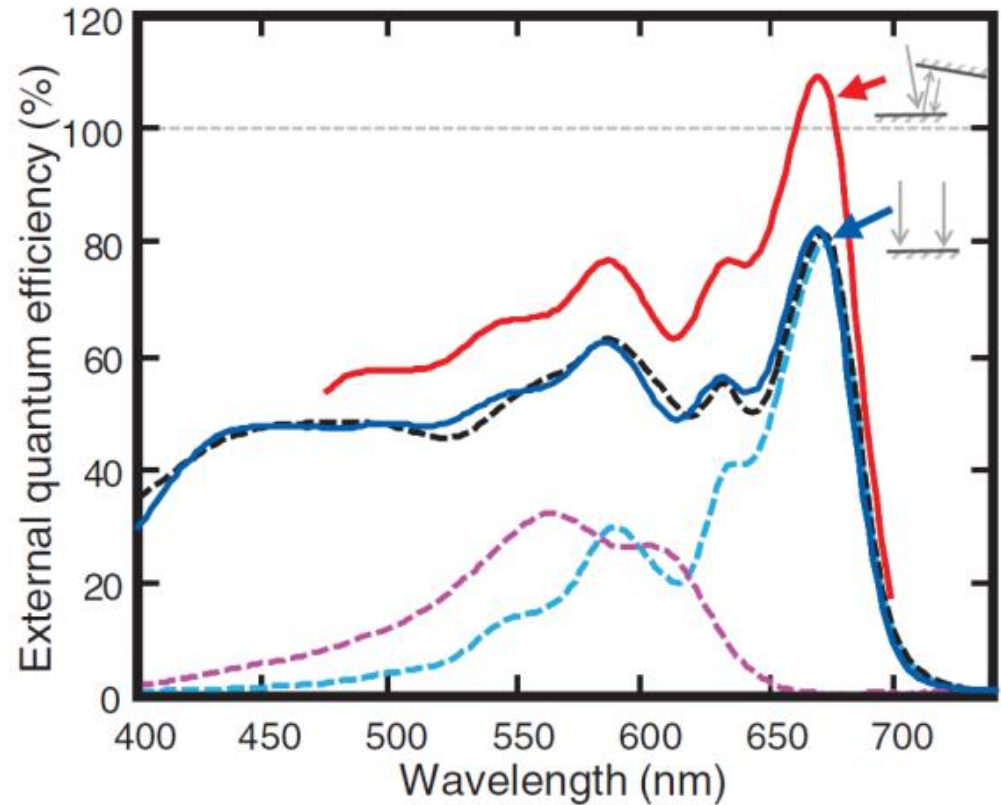
<sup>1)</sup>M. Tabachnyk *et al.*, Nature mat. **13**, 1033 (2014)

<sup>2)</sup>N. J. Thompson *et al.*, Nature mat. **13**, 1039 (2014)

## Singlet fission & triplet dissociation



**EQE > 100% !!!**



Side note: **Tc/C<sub>60</sub>** proved by

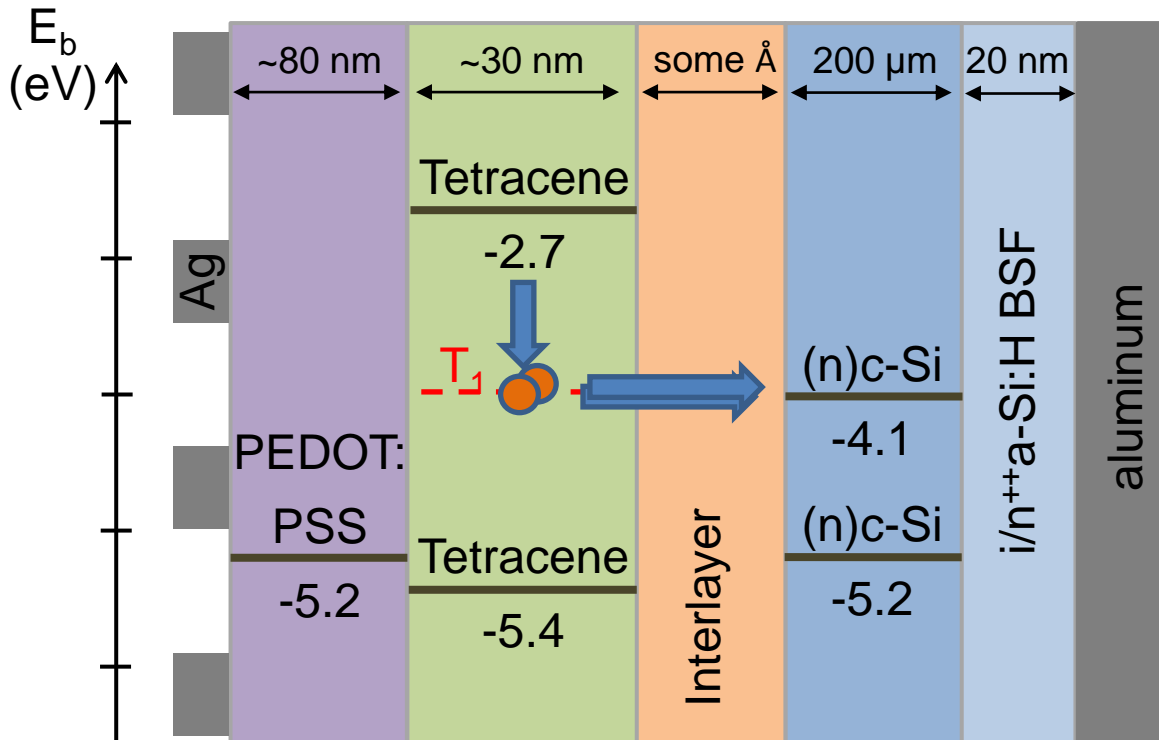
T. C. Wu *et al.*, APL **104**, 193901 (2014)

D. N. Congreve *et al.*, Science **340**, 334 (2013)

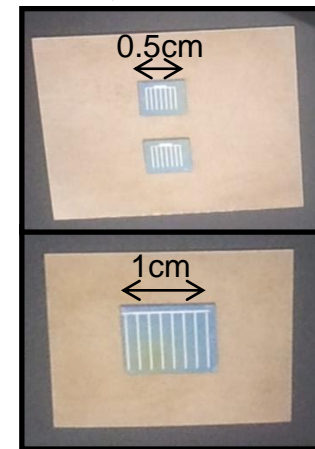
► correct energy (band) alignment important

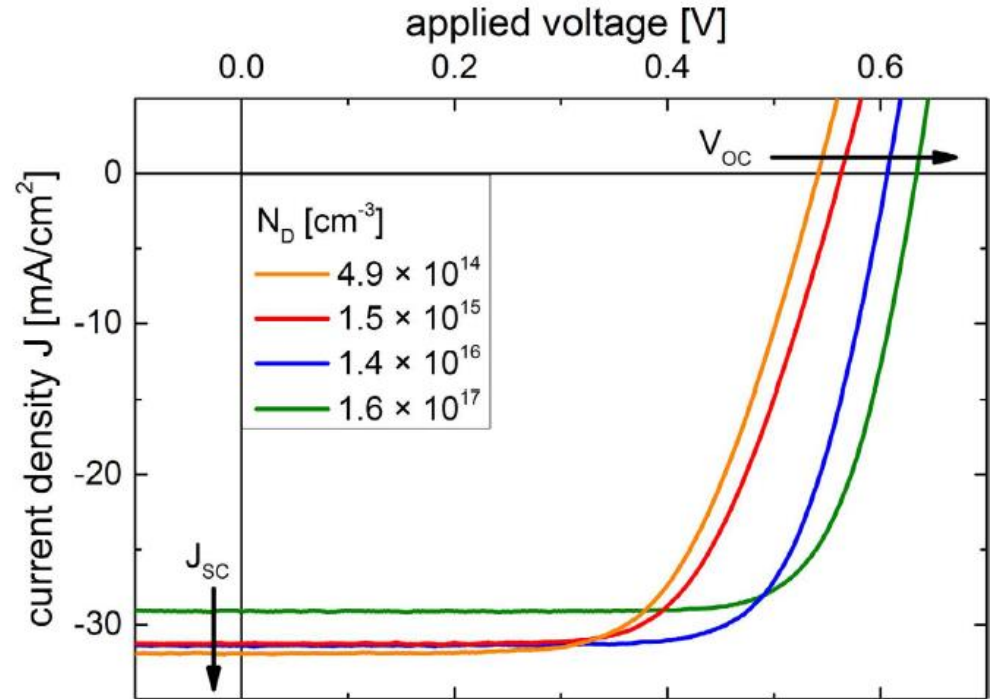
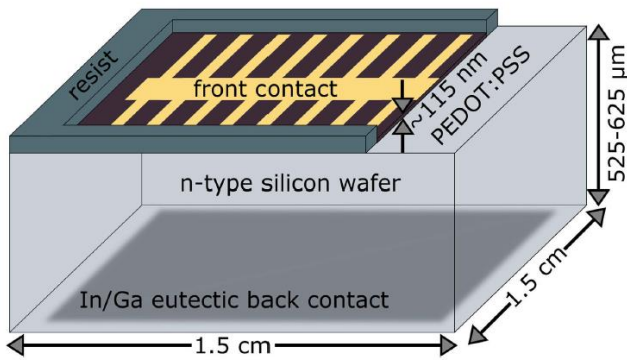
motivation for c-silicon:

- replace pentacene by higher band gap SF material
- proof of charge separation of triplets at hybrid interface



photograph  
of hybrid cells

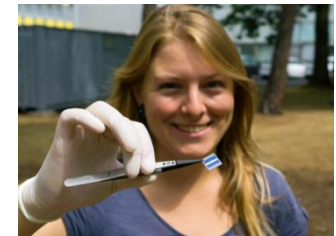




▶ **≈14 % hybrid cell**

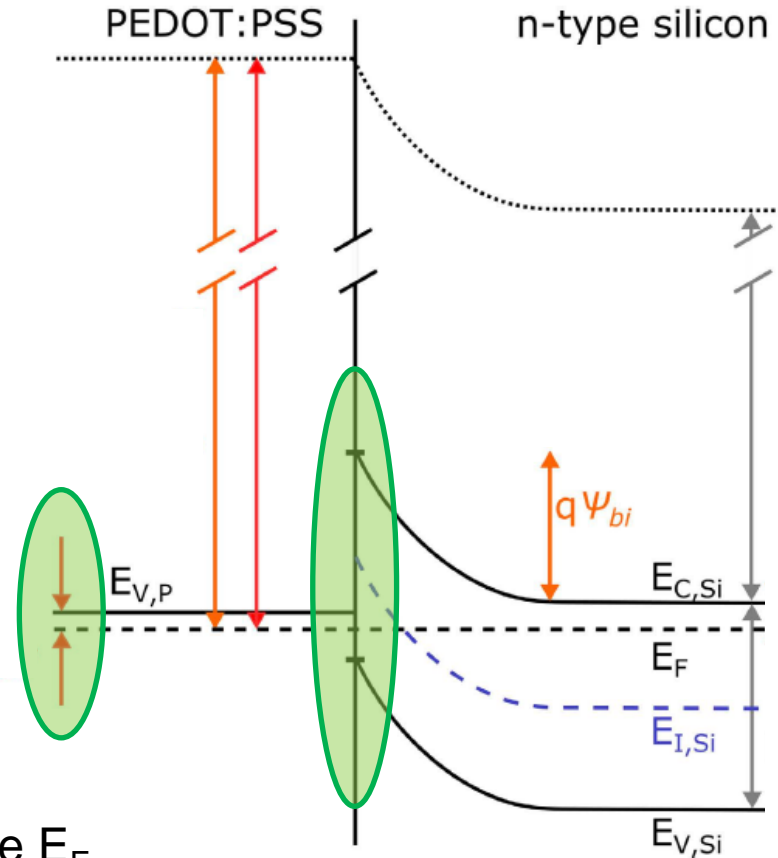
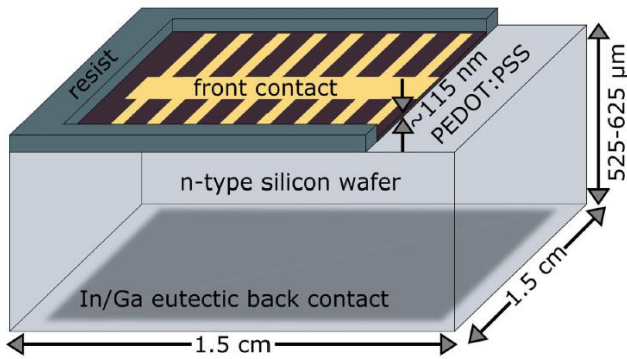
- optimized front contact
- planar, w/o antireflection, “simple” back contact

- ▶ PEDOT:PSS forms a hybrid heterojunction with (n)c-Si  
→ described by **p<sup>+</sup>n-heterojunction**  
(in lit. commonly assumed as Schottky junction)



Sara Jäckle

S. Jäckle, M. Liebhaber *et al.*, *Sci. Rep.* **5**, 13008 (2015)

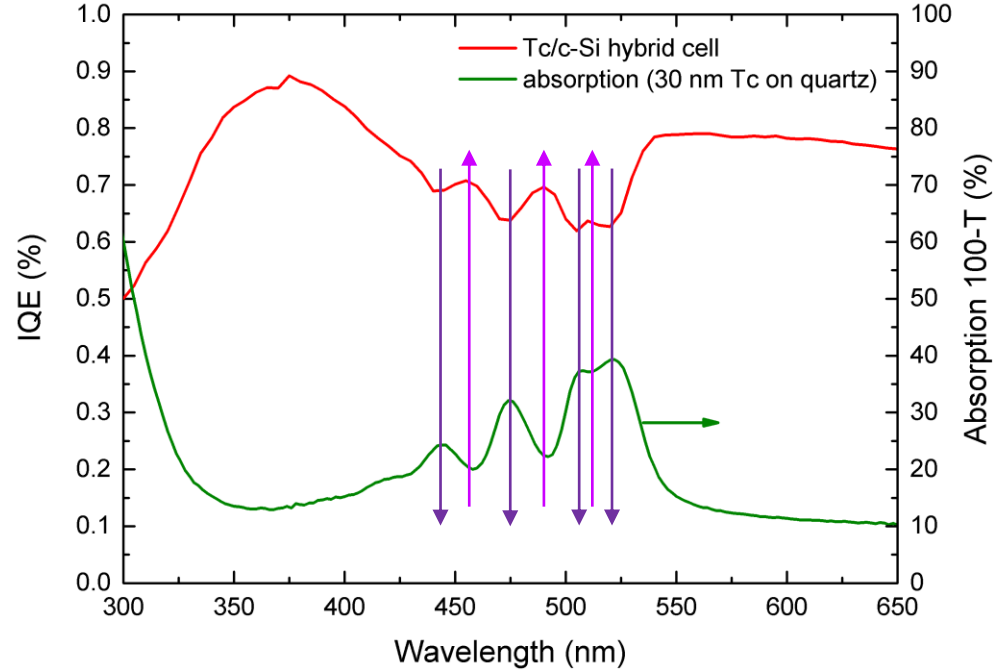
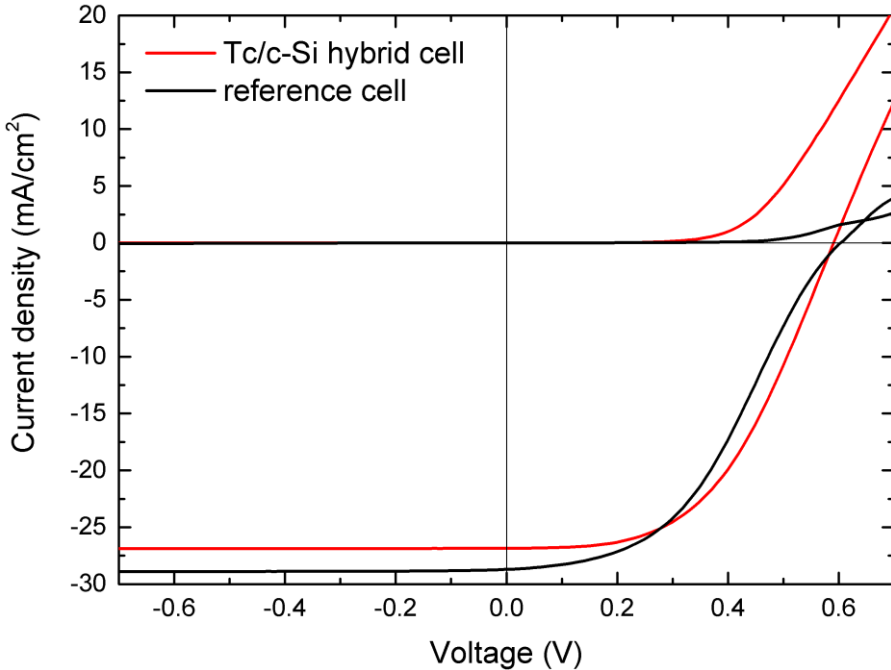


► highly p-doped polymer

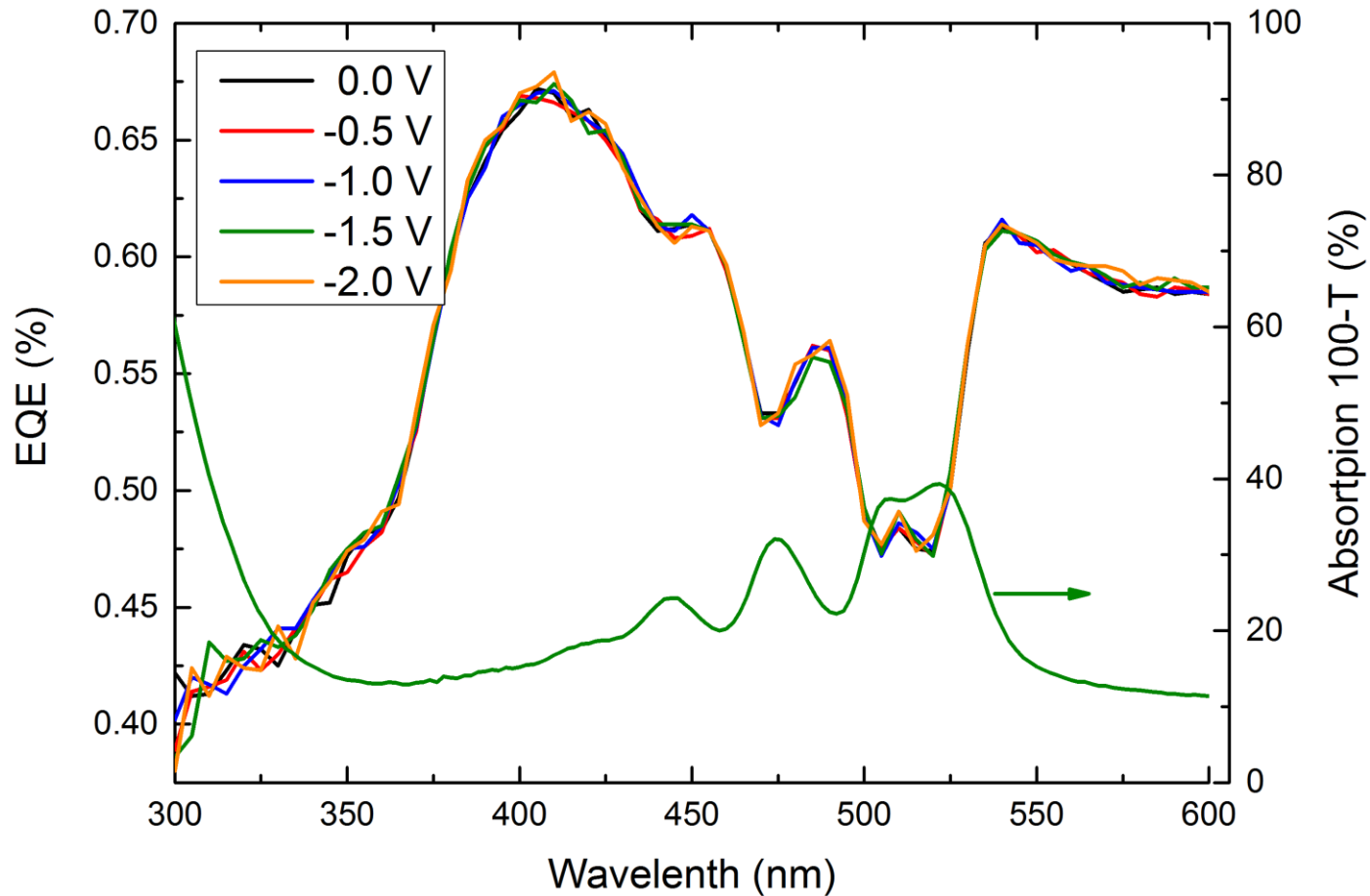
- filled (valence) states at  $E_F$
- valence band edge  $E_{V,P} \approx 80$  meV above  $E_F$

► strong inversion of Si at the surface

→ intrinsic Fermi level  $E_{I,Si}$  crosses  $E_F$  (n-doped Si)

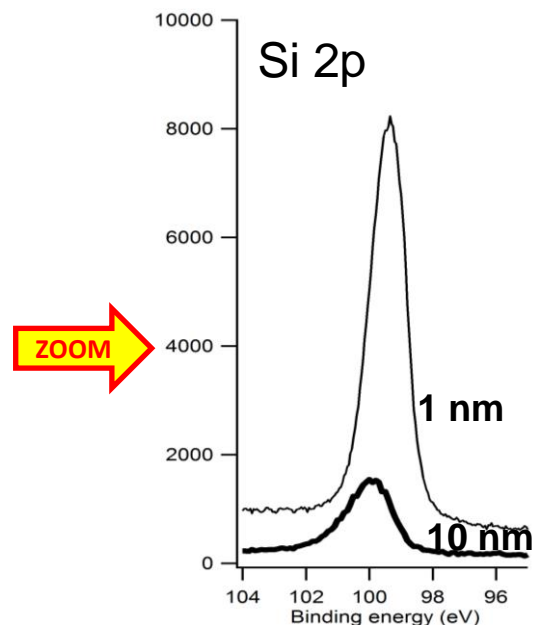


- ▶ absorption spectra reflected in IQE
- ▶ “filter effect” of Tc in IQE, no exciton dissociation

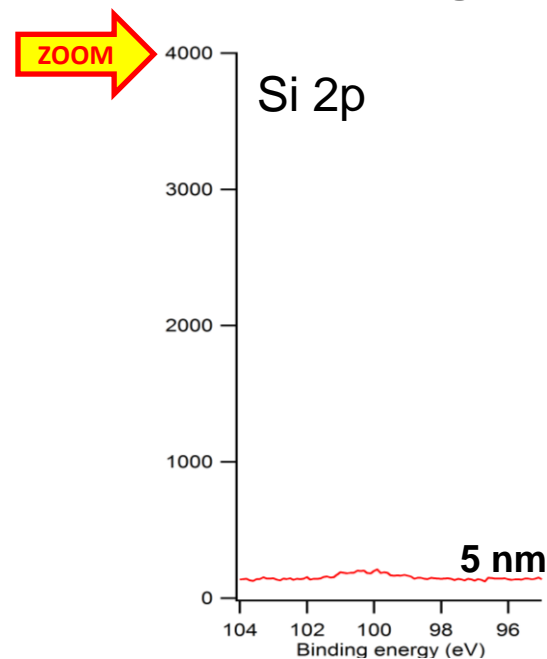


- ▶ no field assisted exciton separation
- ▶ indirect band gap a problem? → phonon assistance? temperature, a-Si:H...

1 nm & 10 nm Tetracene/c-Si  
► island growth



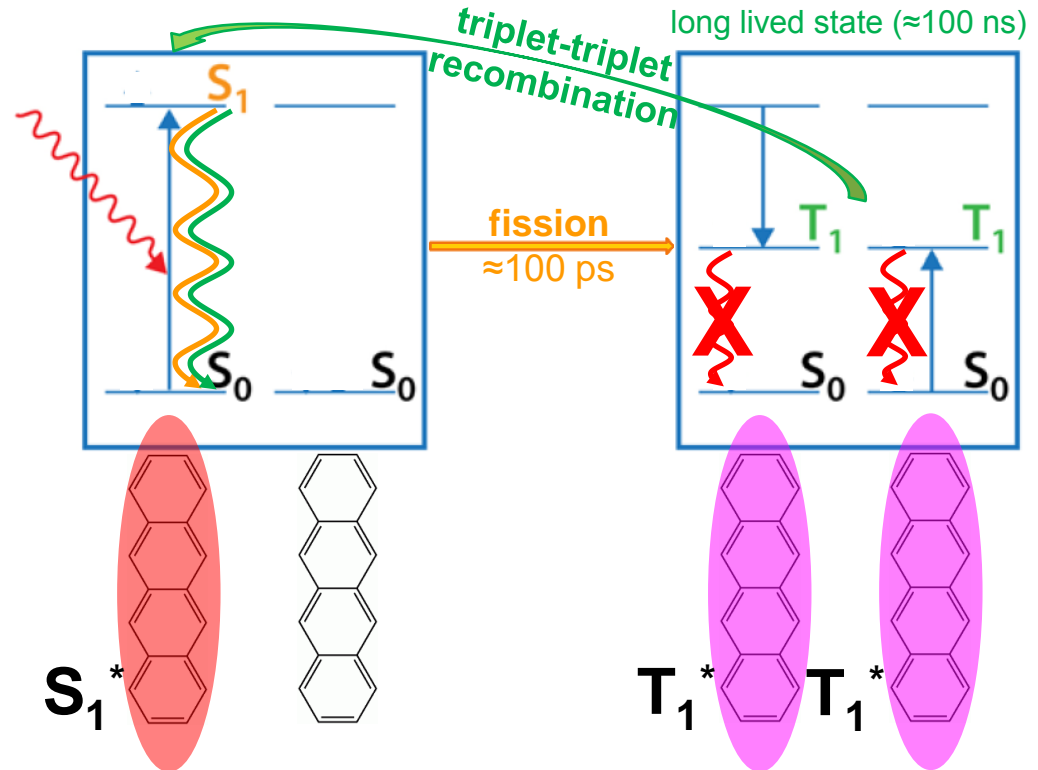
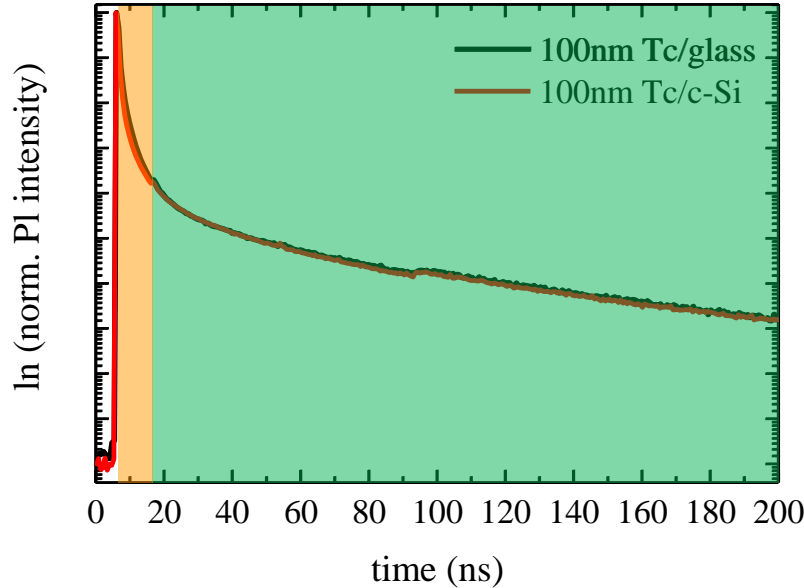
5 nm Pd-Porphyrin/c-Si  
► no island growth



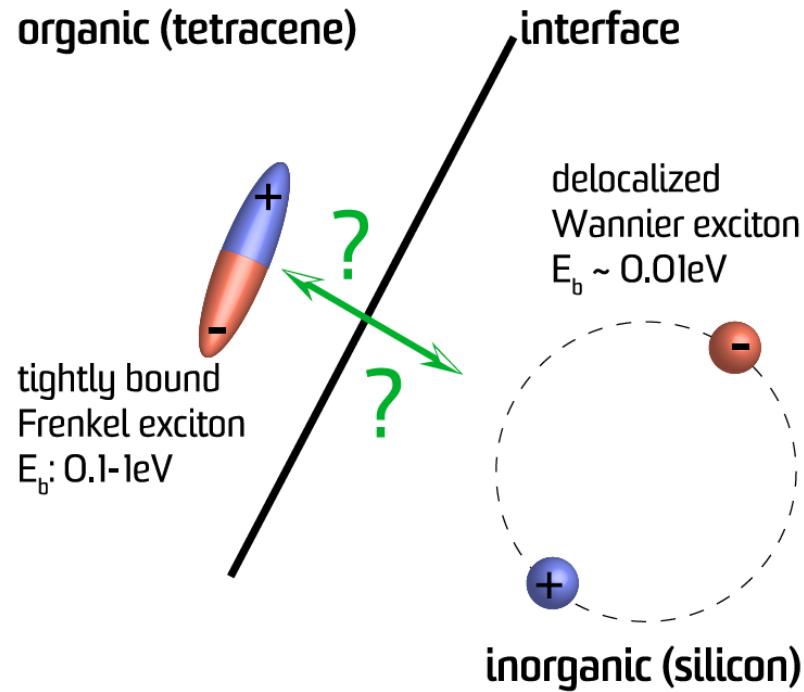


**prompt PL**  
≈ 100 ps

**delayed PL**  
≈ 100 ns



- ▶ first preliminary results: no differences in thickness & substrate variation
- ▶ triplets generated and long lived ( $\approx 100$  ns)
- ▶ singlet fission in Tc layers (also on c-Si) but no injection  $\leftrightarrow$  in accordance to EQE



1. Can correlated triplet excitons be transferred across a silicon interface?
2. How long do the triplets generated upon singlet fission remain geminate?
3. Which interlayers could help to dissociate triplet excitons?

- ▶ overcome fundamental thermalization loss
  - MEG (“spectral downconversion”) via singlet fission

## ultrafast PL measurements:

- polycrystalline Tc thin layers show SF (glass & c-Si substrates)
- no differences in triplet lifetime observed → no exciton dissociation

## hybrid devices:

- hybrid device works, but Tc layers act as filter
- so far no hint for exciton dissociation & charge injection (EQE)

- ▶ search and implementation of organic intermediate layer
  - 1<sup>st</sup> step: charge separation at organic/organic interface works (shown in literature)
  - 2<sup>nd</sup> step: injection of separated charges into c-Si
  - correct band line-up!
- ▶ charge separation at Pb-Nanocrystals works ↔ put on c-Si (Cambridge, MIT...)

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**Thank you for your attention!**  
**Questions & discussion**

**M. Liebhaber**

E-mail: [martin.liebhaber@helmholtz-berlin.de](mailto:martin.liebhaber@helmholtz-berlin.de)

Helmholtz Center Berlin  
Institute for Nanospectroscopy  
Energy Materials In-Situ Lab